

## X射线光电子能谱法研究 $UV_{254\text{ nm}}$ 光催化、 $O_3$ 强化 $UV_{254\text{ nm}}$ 光催化和真空紫外光催化降解甲醛中Pt-TiO<sub>2</sub>薄膜的表面性质

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Characterization of Pt-TiO<sub>2</sub> film used in three formaldehyde photocatalytic degradation systems:  $UV_{254\text{ nm}}$ ,  $O_3 + UV_{254\text{ nm}}$  and  $UV_{254+185\text{ nm}}$  via X-ray photoelectron spectroscopy

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摘要

图/表

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